



Future Normal in Semiconductor

2025-02-13(목), 09:00-10:45

좌장: 추후업데이트 예정

A. Interconnect & Package 분과

[TD1-A] Emerging Interconnect 1

<p>TD1-A-1 09:00-09:15</p>	<p>Frequency Dependency of Cu Flexible Interconnects in Cracking Behavior during Bending Fatigue Jun Hyeok Hyun¹, Seongi Lee², and Sung-Jae Choi², Young-Chang Joo¹, So-Yeon Lee² ¹School of Material Science and Engineering, Kumoh National Institute of Technology, ²Department of Materials Science & Engineering, Seoul National University</p>
<p>TD1-A-2 09:15-09:30</p>	<p>열처리 온도에 따른 Ru/SiGe 계면에서의 반응을 통한 접촉저항 공정 평가 정희윤^{1,4}, 김성준^{2,4}, 박준형^{1,4}, 이태호⁴, 박인성^{3,4}, 신왕철^{1,4}, 박영욱¹, 안진호^{1,2,4} ¹한양대학교 신소재공학과, ²한양대학교 나노반도체공학과, ³한양대학교 나노과학기술연구소</p>
<p>TD1-A-3 09:30-09:45</p>	<p>Influence of Oxygen/Carbon Ratio on Low-k SiCOH Film Deposited by PECVD Using a Novel C₅H₁₆OSi Precursor Sangwoo Lee¹, Joonbong Lee¹, Hyunbin Chung¹, Dae Haa Ryu¹, Heeseo Yun¹, Taekjib Choi¹, Jaejin Hwang², Jaekwang Lee², In Gyu Choi³, Hyojun Jung³, Kwangwoo Lee³, Sanghak Yeo³, Sungwoo Lee³, Jaeyoung Yang³, Ho Jung Jeon⁴, and You Seung Rim⁴ ¹Hybrid Materials Research Center, Department of Nanotechnology and Advanced Materials Engineering, Sejong University, ²Department of Physics, Pusan National University, ³Research and development laboratory, TES, ⁴Department of Semiconductor Systems Engineering and Convergence Engineering for Intelligent Drone, Sejong University</p>
<p>TD1-A-4 09:45-10:00</p>	<p>나노 초 그린 레이저 어닐링을 활용한 Contact/via 접촉 불량 해소 정재중¹, 박영근¹, 김영준¹, 김희태¹, 김동빈¹, 조희재², 권수현², 조병진¹ ¹한국과학기술원 전기및전자공학부, ²나노종합기술원 나노공정기술실</p>
<p>TD1-A-5 10:00-10:15</p>	<p>초미세 반도체 소자용 후면 전력 공급 기술(BSPDN) 특허 출원 동향 방기인, 안치복, 김희태 특허청 반도체심사추진단</p>



제 32회 한국반도체학술대회

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초청 TD1-A-6 10:15-10:45	Atomic Layer Deposition of Platinum Group Metals for Next-Generation Interconnects Minsu Kim Kyonggi University
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